



GREAT² 3.1 TID Test Results

26/02/2019









- ESA Project
 - GREAT2 Phase 3.1 GaN Process Performance Validation and Space Evaluation (GH50_20)
 - ESA Contract No. 4000116120/16/NL/BJ
- Total Ionisation Dose Radiation Test (Co60)
- Hardware
 - Technology: 4GH50-20 GaN Power Bar
 - 100W power bar in Kyocera package
 - Manufacturer: United Monotlithic Semiconductor
- 10 devices submitted to Co60 irradiation source, up-to 274Krad (in GaN)

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- 2 units biased at Vgs = 0V / Vds = 0V
- 3 units biased at Vgs = -7V / Vds = 50V
- 5 units biased at Vgs = -7V / Vds = 80V
- All the measurements performed during the radiation period, during intermediate characterization steps, and before/after an annealing period at the end of the radiation period did not exhibit any relevant variation of the electrical characteristics of the devices, whatever their biasing conditions during radiation.











- Total ionizing dose assessed by submitting devices to a Co60 irradiation source (Estec Co-60 Facility).
- Devices pinched off during the test.
 - Vgs = 0V Vds = 0V => 2 units
 - Vgs = -7V Vds = 50V => 3 units
 - Vgs = -7V Vds = 80V => 5 units
- Scheduled radiation campaign

Target Total Dose (*)	Target Dose Rate (*)	Estimated Distance	lenght of available	Irradiation Time	Start	Stop
[rad]	[rad/min]	[m]	irradiation [m]	[min]	[dd-mmm-yyyy hh:mm]	
110,000	27	1.004	0.44	4,074.07	26-Nov-2018 13:30	29-Nov-2018 09:24
300,000	27	1.004	0.44	7,037.04	29-Nov-2018 13:24	04-Dec-2018 10:41

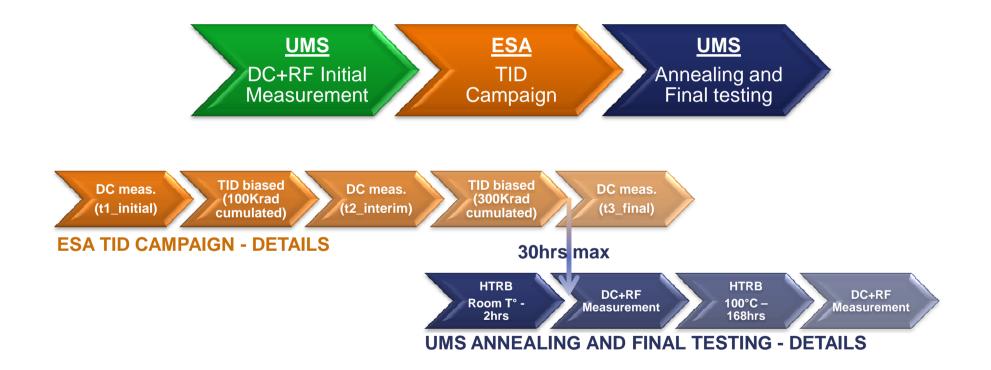
(*) The figures of dose and dose rate indicated in this document shall be dose to Si.







TID Test Sequence





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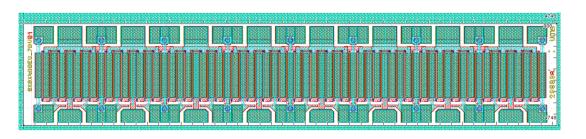


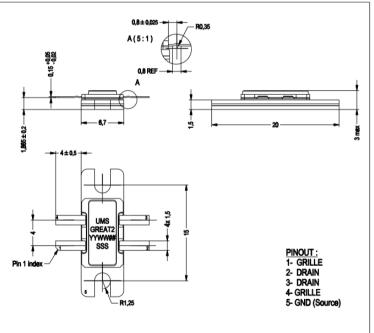






- Technology : GaN 4GH50-20
- Maskset: NOUMEAC
- Design:
 - 23693A
 - 8x8x400EU_70V1
 - 100W Power Bar
 - Reliability Lot : U460418
- Die soldered with AuSn eutectic into closed Metal Ceramic Package (Kyocera) Package





General tolerance ±0.15 Base : Cu-Mo-Cu. Ni Plate 2.0µm min. - Au Plate 1.0µm min. Lead : Cu. Ni Plate 2.0µm min. - Au Plate 1.0µm min.

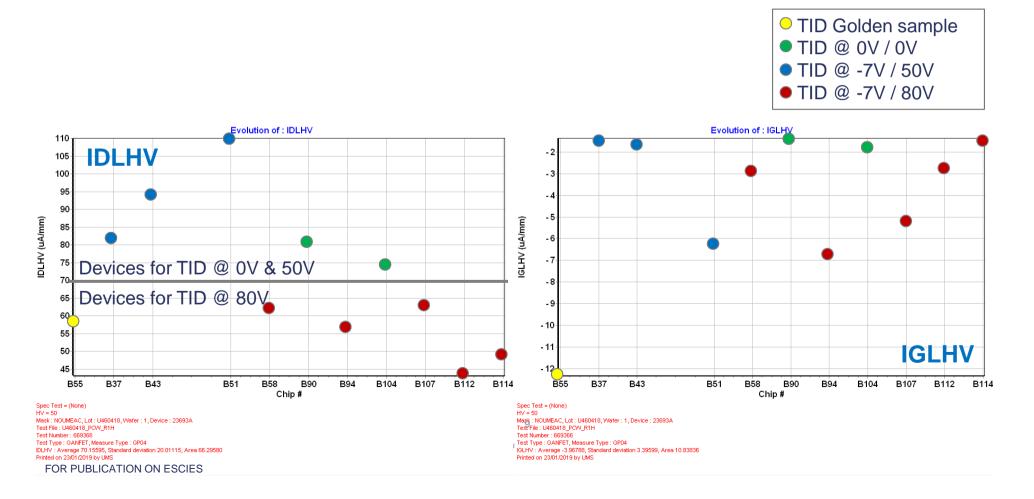


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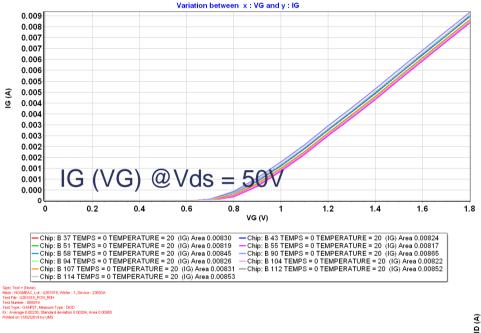
- Initial Measurements on pre-Selected Devices
 - As TID tests were managed by using common drain biasing and common gate biasing, the 11 devices were specially selected in order to get quite low dispersion on IDLHV and IGLHV

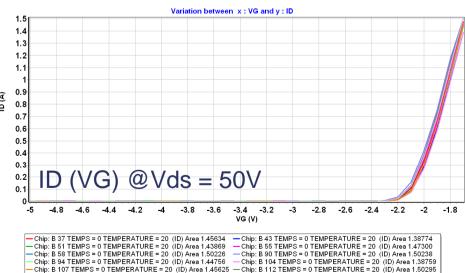






Initial Measurements on pre-Selected Devices



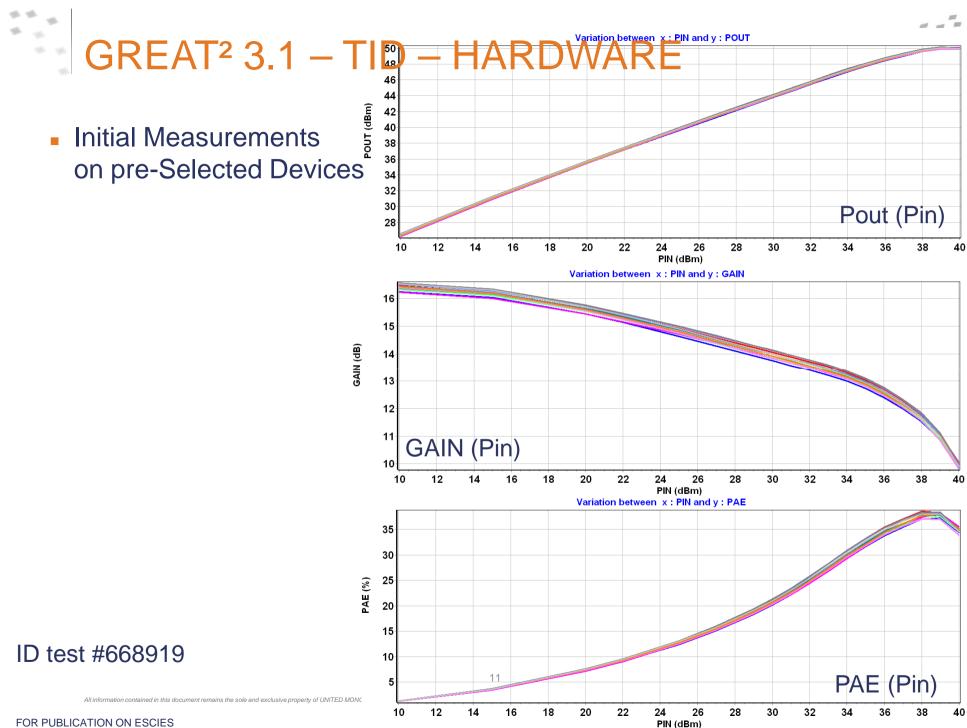


ID test #668919

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Set Ext - (knore) V0 = 4, 4, 4, 4, 7, 46, 45, 44, 43, 42, 41, 4, 38, 38, 37, 36, 35, 34, 33, 32, 31, 3, 28, 28, 27, 28, 25, 24, 23, 22, 21, 2, 18, 17 Main: Nouther (La Lubiolity, NMH Tent File: Nouther (La Lubiolity, NMH NMH) NMH (La Lubiolity, N

Chip: B 114 TEMPS = 0 TEMPERATURE = 20 (ID) Area 1.50295

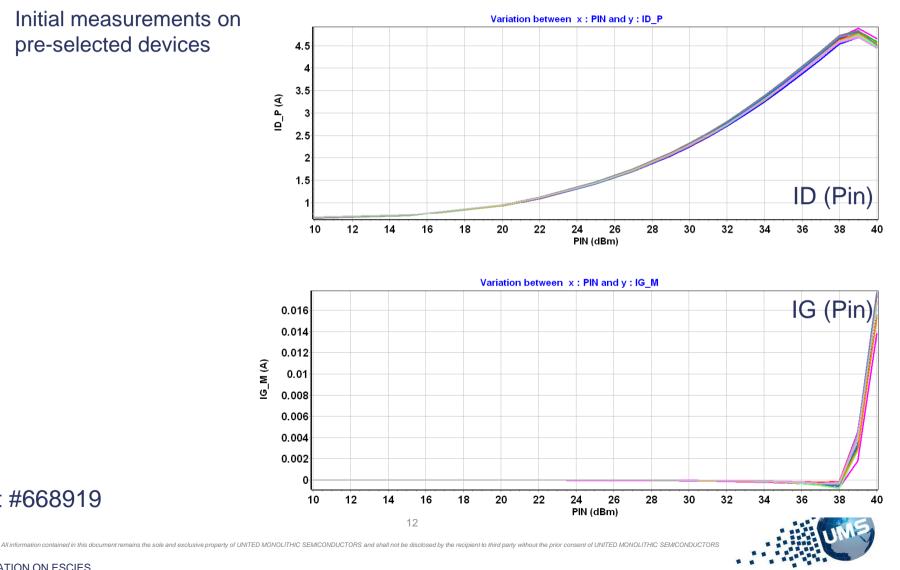


FOR PUBLICATION ON ESCIES





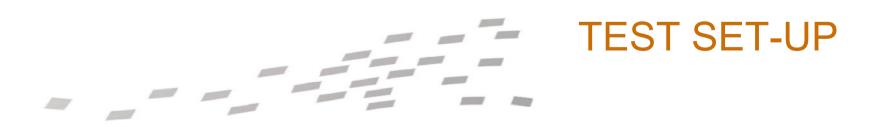
- Hardware
 - Initial measurements on pre-selected devices



FOR PUBLICATION ON ESCIES

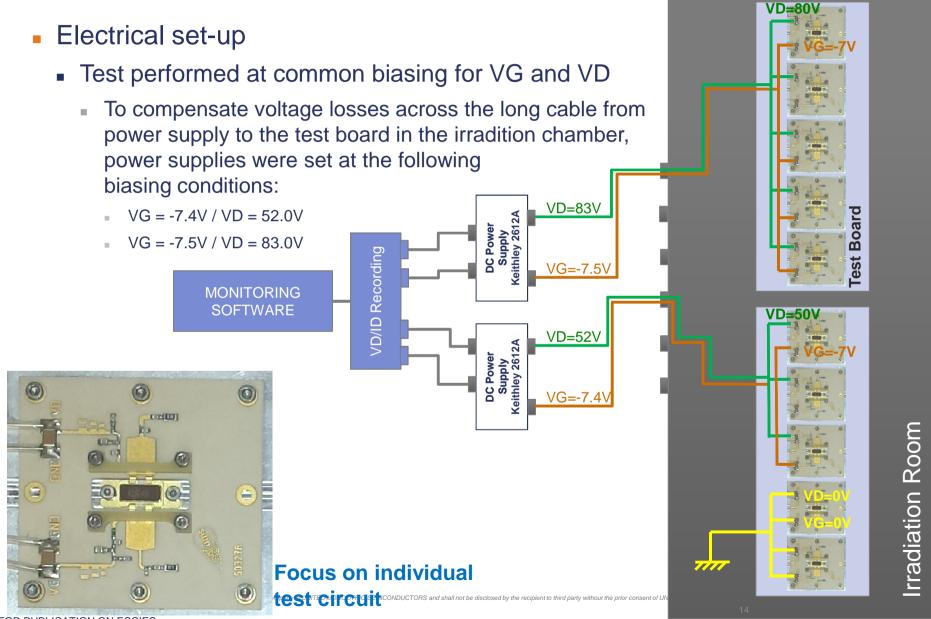
ID test #668919



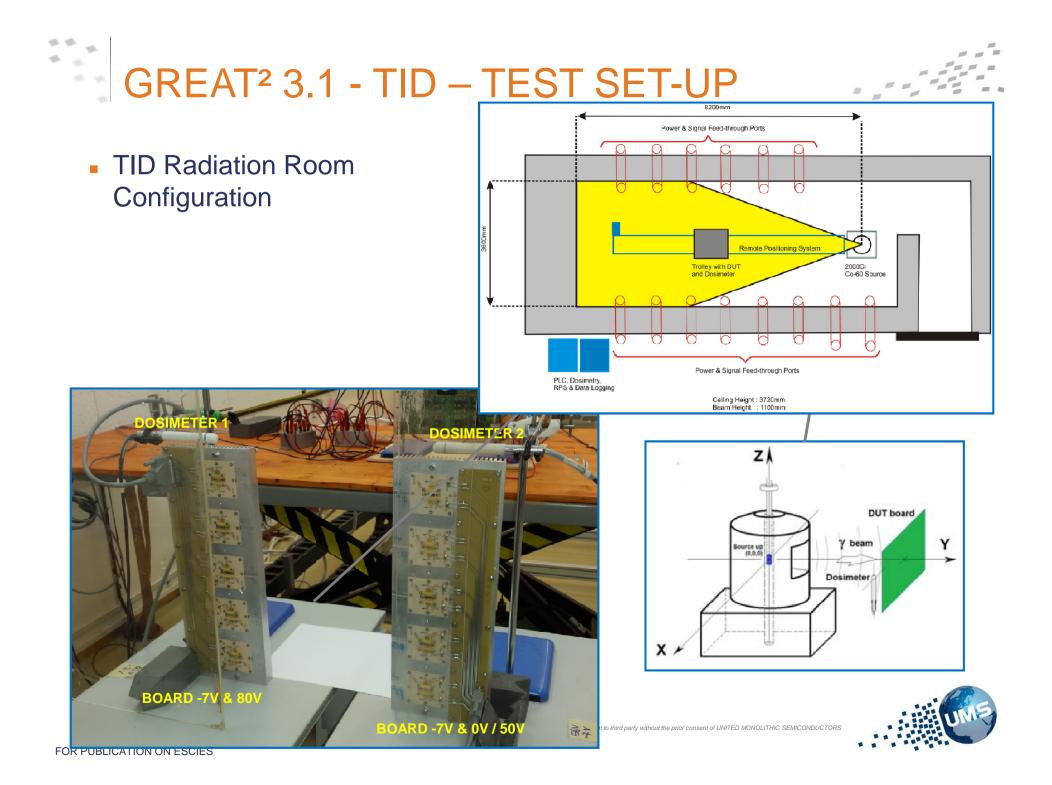


GREAT² 3.1 – TID – TEST SET-UP





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- Data Monitoring
 - Power Supplies were set at
 - VG = -7.4V / VD = 52.0V
 - VG = -7.5V / VD = 83.0V
 - Individual device biasing were recording on the board before and after at each TID step
 - No specific changes occurred all along the test

	BEFORE FIRST RADIATION STEP		AFTER FIRST RADIATION STEP		BEFORE SECOND RADIATION STEP		AFTER SECOND RADIATION STEP	
BOARD 80V	t=0h (26/11	/2018 15:30)	t=100kRads (29	/11/2018 11:00)	t=100kRads (29	/11/2018 18:00)	t=300Krad (04/	/1 <mark>2/201</mark> 8 10:10)
DUT	VD_MEAS;	VG_meas.	VD_meas.	VG_meas.	VD_meas.	VG_meas.	VD_meas.	VG_meas.
B58	81.3 V	-7.2 V	82.1 V	-7.3 V	81.9 V	-7.2 V	82.2 V	-7.3 V
B94	79.8 V	-7.0 V	81.4 V	-7.1 V	80.8 V	-7.0 V	81.6 V	-7.2 V
B107	80.6 V	-7.0 V	81.9 V	-7.3 V	81.5 V	-7.2 V	82.0 V	-7.3 V
B112	81.6 V	-7.2 V	82.2 V	-7.3 V	81.9 V	-7.3 V	82.3 V	-7.3 V
B114	82.0 V	7.3 V	82.4 V	7.4 V	82.2 V	7.3 V	82.4 V	7.4 V
[BEFORE FIRST RADIATION STEP		AFTER FIRST RADIATION STEP		BEFORE SECOND RADIATION STEP		AFTER SECOND RADIATION STEP	
	t=0b (26/11	h (26/11/2018 15:30) t=100kRads (/11/2018 11:00)	t=100kRads (29/11/2018 18:00)		t=300Krad (04/12/2018 10:10)	
BOARD 50V	(-011 (20) 11)	2010 10.30						
BOARD 50V DUT	VD_meas.	VG_meas.	VD_meas.	VG_meas.	VD_meas.	VG_meas.	VD_meas.	VG_meas.
			VD_meas. 51.6 V	VG_meas. -7.3 V	VD_meas. 51.5 V	VG_meas. -7.3 V	VD_meas. 51.6 V	VG_meas. -7.3 V
	VD_meas.	VG_meas.				_	-	
DUT B37	VD_meas. 51.3V	VG_meas. -7.3V	51.6 V	-7.3 V	51.5 V	-7.3 V	_ 51.6 V	-7.3 V
DUT B37 B43	VD_meas. 51.3V 51.2V	VG_meas. -7.3V -7.2V	51.6 V	-7.3 V -7.3 V	51.5 V 51.5 V	-7.3 V -7.3 V	51.6 V 51.6 V	-7.3 V -7.3 V

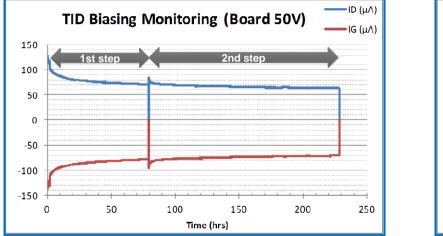


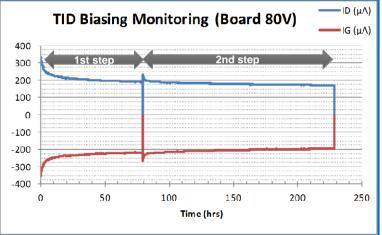






- Data Monitoring
 - IG and ID were in-situ monitored during the radiation test
 - No specific changes occurred all along the test







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Data Monitoring

- Co60 dose rate was monitored all along the test
 - It is to be noticed that the initial target of 300 Krad was not reached due to external constraints that obliged to reduce the dose rate to ~22 rad/min, leading to a total cumulated dose of 274 Krad (in GaN). This value remains far from the standard dose of 100Krad.

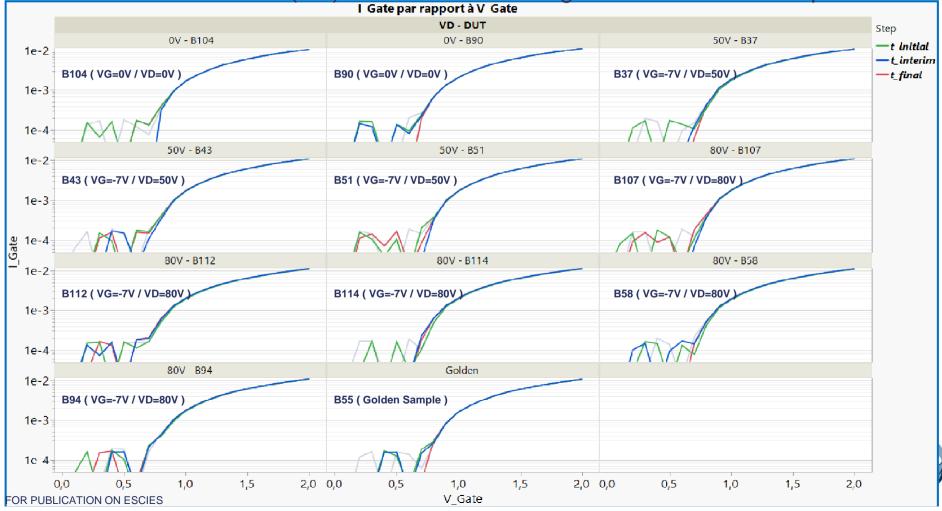
Deens Sten	Start	End	Total Ionising Dose	Dose Rate
Beam Step	Date & Time (CET)	Date & Time (CET)	(GaN)	(GaN)
1	26-11-2018 15:43	27-11-2018 10:23	24 082 rad	21.49 rad/min
2	27-11-2018 10:38	27-11-2018 12:14	2 163 rad	22.52 rad/min
3	27-11-2018 12:40	28-11-2018 10:13	28 965 rad	22.40 rad/min
4	28-11-2018 10:49	28-11-2018 12:19	2 019 rad	22.40 rad/min
5	28-11-2018 12:29	29-11-2018 10:33	29 677 rad	22.41 rad/min
6	29-11-2018 10:50	29-11-2018 15:56	6 860 rad	22.41 rad/min
First step			93 766 rad	
7	29-11-2018 18:15	30-11-2018 11:09	22 806 rad	22.48 rad/min
8	30-11-2018 11:35	30-11-2018 13:14	2 240 rad	22.48 rad/min
9	30-11-2018 13:24	30-11-2018 18:35	6 996 rad	22.51 rad/min
10	30-11-2018 18:54	03-12-2018 10:02	85 154 rad	22.47 rad/min
11	03-12-2018 10:12	03-12-2018 14:04	5 208 rad	22.50 rad/min
12	03-12-2018 14:10	03-12-2018 16:45	3 487 rad	22.47 rad/min
13	03-12-2018 17:09	04-12-2018 10:37	23 550 rad	22.48 rad/min
14	04-12-2018 10:43	04-12-2018 12:38	2 588 rad	22.47 rad/min
15	04-12-2018 12:45	05-12-2018 9:59	28 630 rad	22.48 rad/min
Second step			180 659 rad	
Gran Total			274 424 rad	



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... -- - --GREAT² 3.1 - TID -**FST RESULTS** TID biased TID biased DC meas. DC meas. DC meas. (100Krad (300Krad (t2 interim) (t3 final) cumulated) cumulated)

- Interim Measurements Data Analysis
 - Forward IG(VG) characteristics
 - => No evolution of IG(VG) characteristics during the radiation beam exposure



GREAT² 3.1 - TID - TEST RESULTS DC meas. TID biased (100Krad DC meas. TID biased (300Krad

- Interim Measurements Data Analysis
 - Reverse IG(VG) characteristics
 - => Low variation of IG(VG) characteristics during radiation beam exposure

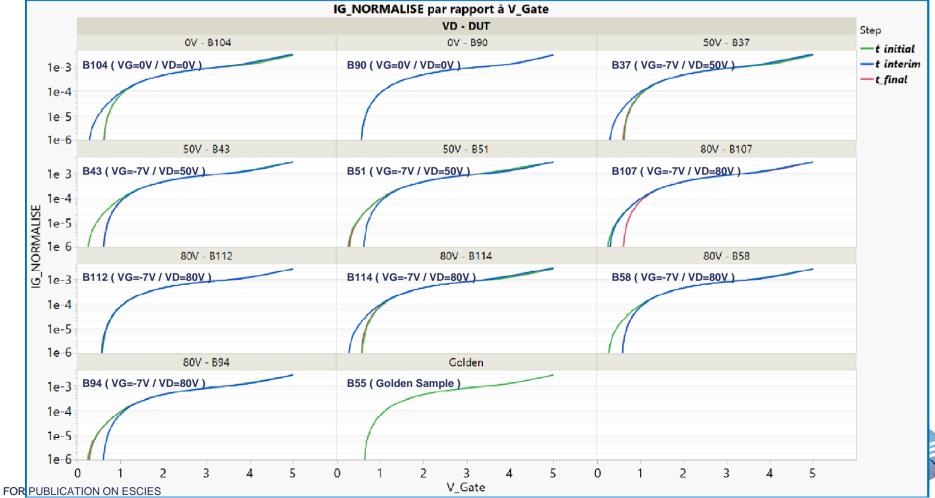
cumulated)

(t2_interim)

cumulated)

DC meas.

(t3_final)



- - -1 GREAT² 3.1 - <u>TID</u> – **FST RESULTS** TID biased DC meas. DC meas.

- Interim Measurements Data Analysis
 - ID(VD) characteristics

**

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=> Low variations of ID(VD) characteristics during the radiation beam exposure

(100Krad

cumulated)

(t2_interim)

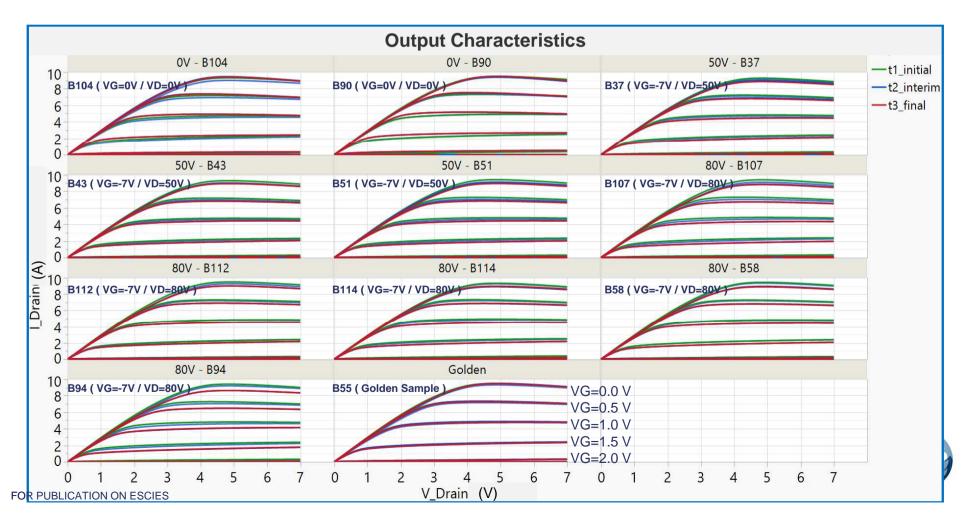
TID biased

(300Krad

cumulated)

DC meas.

(t3_final)



GREAT² 3.1 - <u>TID –</u> TEST RESULTS TID biased

DC meas.

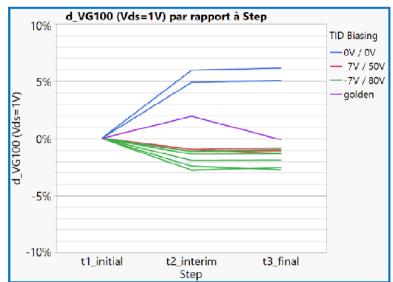
- Interim Measurements Data Analysis
 - DC parameters

...

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- Idss, VG100, IDLHV (40V) variations
- => Low impact of radiations on DC characteristics.
 - VG100 : Main variations observed on grounded units
 - Idss: Correlation is observed between drain Voltage and Idss decrease after first step, but lower discrimination at the end of radiation campaign



TID biased

(300Krad

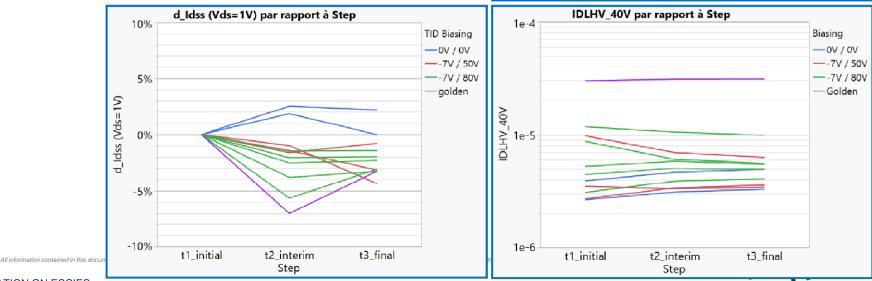
cumulated)

DC meas.

(t3 final)

DC meas.

(t2 interim)



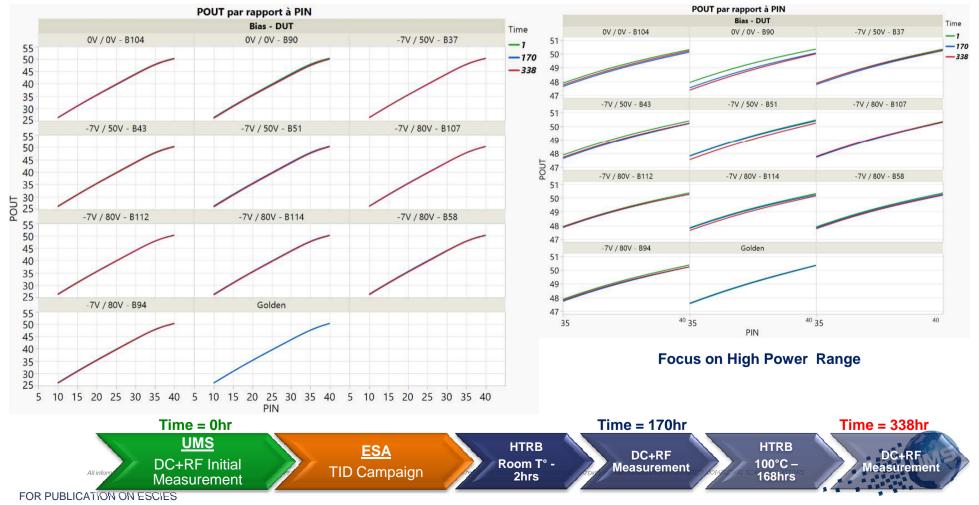
(100Krad

cumulated)





- TID Test + Annealing Step
 - RF characteristics
 - => Low impact of radiations on DC







- TID Test + Annealing Step
 - RF characteristics

=> No significant variation on RF power high level, and on gate current leakage Note: reference device failed during last sequence of RF measurement

